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Construction and Characterization of Photodiodes prepared with Bi₂S₃ Nanowires

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This work discloses the characteristics of a Bi₂S₃ nanowire / ITO photodiode and a manufacture method thereof; wherein, the high-crystalline Bi₂S₃ nanostructures were prepared by an environmental friendly dip-coating method onto Indium-doped Tin Oxide (ITO) coated glass substrates using bismuth nitrate and thiourea as raw material with DMF as solvent. The XRD spectra showed that the Bi₂S₃ nanowire exhibits orthorhombic structure, while the SEM images revealed the formation of uniform sized nanowires with diameter around 15.8 nm. The optical bandgap of the films had been estimated via Tauc plot and found to be in the range of 1.85 eV - 1.9 eV. In order to understand the I-V characterizations of the prepared diode showed prominent photo-response with a high photo-responsivity of 1.7 μ A with a fast response time were reported in detail.

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